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09/991196
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	Class	Subclass
ISSUE CLASSIFICATION		

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PATENT NUMBER

U.S. **UTILITY** Patent Application

m/e O.I.P.E. SCANNED <u>TR2</u> O.A. <u>S</u>	PATENT DATE
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APPLICATION NO. 09/991196	CONT/PRIOR D	CLASS 216	SUBCLASS 1.1	ART UNIT 1711	EXAMINER J. J. J.
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APPLICANTS

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TITLE

High density plasma chemical vapor deposition process

PTO-2040
12/89

ISSUING CLASSIFICATION								
ORIGINAL		CROSS REFERENCE(S)						
CLASS	SUBCLASS	CLASS	SUBCLASS (ONE SUBCLASS PER BLOCK)					
INTERNATIONAL CLASSIFICATION								

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<input type="checkbox"/> TERMINAL DISCLAIMER	DRAWINGS			CLAIMS ALLOWED	
	Sheets Drwg.	Figs. Drwg.	Print Fig.	Total Claims	Print Claim for O.G.
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	_____ (Primary Examiner) _____ (Date)			ISSUE FEE	
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